

## AMENDMENT TO CLAIMS

### *In the Claims*

Please **AMEND** claims 19-22 as follows:

A list of the claims and a status of each claim is provided below.

1.-18. (Cancelled)

19. (Currently Amended) An active matrix display device, comprising:  
an insulation substrate;  
a thin film transistor formed on the insulation substrate, including a semiconductor layer where source/drain regions are formed, gate electrode and source/drain electrodes respectively connected to the source/drain regions;  
an insulation film formed over the insulation substrate, having an opening portion; and  
a pixel electrode as a lower electrode,  
wherein the source/drain electrodes have a dual-layered structure of a transparent conductive layer and a metal layer, the metal layer being ~~covered~~ enclosed by the insulation film,  
wherein the pixel electrode ~~extending~~ extends from a portion of the transparent conductive layer forming any one of the source/drain electrodes and is exposed through the opening portion of the insulation film.

20. (Currently Amended) The active matrix display device according to claim 19, wherein the insulation ~~layer~~ film is a passivation layer patterned to cover the metal ~~layers~~ layer of the source/drain electrodes.

21. (Currently Amended) The active matrix display device according to claim 19, wherein the insulation ~~layer~~ film is a passivation layer reflowed to ~~cover~~ enclose the metal ~~layers~~ layer of the source/drain electrodes.

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22. (Currently Amended) The active matrix display device according to claim 19, further comprising an organic EL layer formed on a portion of the pixel electrode exposed through the opening portion, wherein the organic EL layer is insulated from the metal ~~layers~~ layer of the source/drain electrodes.